|  | Application No.  | pplication No. Applicant(s)  |                                |  |
|--|--|--|--------------------------------|--|
| Notice of Allowability   | 10/807,000   | KIM ET AL.   |                                |  |
|  | Examiner   | Art Unit   |                                |  |
|  | Thinh T. Nguyen  | 2818   |                                |  |
|  | Thinit I. Nguyen   | 2010   |                                |  |
| The MAILING DATE of this communication appeall claims being allowable, PROSECUTION ON THE MERITS IS nerewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT Report the Office or upon petition by the applicant. See 37 CFR 1.313   | (OR REMAINS) CLOSED in<br>or other appropriate commu<br>IGHTS. This application is s | n this application. If not inclu<br>unication will be mailed in du | ıded<br>ıe course. <b>THIS</b> |  |
| 1. This communication is responsive to 10/3/2005.  | ·  |  |                                |  |
| 2. ☑ The allowed claim(s) is/are <u>1-22 and 36-41</u> .   |  |  |                                |  |
| <ol> <li>Acknowledgment is made of a claim for foreign priority under the priority and all block by all</li></ol> |  | or (f).  |                                |  |
| <ol><li>Certified copies of the priority documents have</li></ol>  | e been received in Applicatio  | n No   |                                |  |
| <ol><li>Copies of the certified copies of the priority do</li></ol>  | cuments have been received   | d in this national stage applic                                    | cation from the                |  |
| International Bureau (PCT Rule 17.2(a)).   |  |  |                                |  |
| * Certified copies not received:   |  |  |                                |  |
| Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  |  | a reply complying with the i                                       | requirements                   |  |
| 4. A SUBSTITUTE OATH OR DECLARATION must be subm<br>INFORMAL PATENT APPLICATION (PTO-152) which give   | nitted. Note the attached EXA<br>es reason(s) why the oath or                        | AMINER'S AMENDMENT or declaration is deficient.                    | NOTICE OF                      |  |
| 5. CORRECTED DRAWINGS ( as "replacement sheets") mus   | st be submitted.   |  |                                |  |
| (a) ☐ including changes required by the Notice of Draftspers   | son's Patent Drawing Reviev  | v ( PTO-948) attached  |                                |  |
| 1)  hereto or 2)  to Paper No./Mail Date   |  |  |                                |  |
| (b) including changes required by the attached Examiner<br>Paper No./Mail Date   | s Amendment / Comment or   | in the Office action of  |                                |  |
| Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t   | .84(c)) should be written on the header according to 37 CF                           | he drawings in the front (not t<br>R 1.121(d).                     | :he back) of                   |  |
| <ol> <li>DEPOSIT OF and/or INFORMATION about the depo<br/>attached Examiner's comment regarding REQUIREMENT</li> </ol>   | sit of BIOLOGICAL MATE<br>FOR THE DEPOSIT OF BIO                                     | ERIAL must be submitted<br>DLOGICAL MATERIAL.                      | . Note the                     |  |
|  |  |  |                                |  |
| ·  |  |  |                                |  |
|  |  |  |                                |  |
|  |  |  |                                |  |
| Attachment(s)  | E Malian atta  | formal Datant Application (D                                       | TO 452)                        |  |
| 1. Notice of References Cited (PTO-892)  | <u> </u>   | formal Patent Application (P                                       | 10-152)                        |  |
| 2. Notice of Draftperson's Patent Drawing Review (PTO-948)   |  | 6. ☐ Interview Summary (PTO-413), Paper No./Mail Date              |                                |  |
| <ol> <li>Information Disclosure Statements (PTO-1449 or PTO/SB/0<br/>Paper No./Mail Date</li> </ol>  |  | Amendment/Comment  |                                |  |
| Examiner's Comment Regarding Requirement for Deposit of Biological Material  | 8. 🛭 Examiner's  | 8. X Examiner's Statement of Reasons for Allowance                 |                                |  |
| oi biological Material   | 9. 🗌 Other   | - Mm ~   | $\sim_{\gamma}$                |  |
|  |  | v<br>Ngan Van Ng<br>Siman Evanii                                   |                                |  |

## **DETAILED ACTION**

## Examiner's Amendment.

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Change the title to:

-- INTEGRATED CIRCUIT DEVICES WITH METAL-INSULATOR-METAL CAPACITORS --

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## Reason for allowance

2. Claims 1-22,36-41 are allowed. The following is an examiner's statement of reason for allowance:

I/ Group I: Claims 1-12,36-37,40

Claims 1-12,36-37,40 are allowed because None of the references of record teaches or suggests the claimed INTEGRATED CIRCUIT DEVICES WITH METAL-INSULATOR-METAL CAPACITORS DEVICE having the limitations:

-- "a dielectric layer on the substrate. a conductive contact plug extending through an opening in the dielectric layer to contact the substrate and including a widened pad portion extending onto the dielectric layer adjacent the opening; an ohmic pattern on the pad portion of the plug; a barrier pattern on the ohmic pattern; a concave first capacitor electrode disposed on the barrier pattern and defining a cavity opening away from the substrate, a capacitor dielectric layer conforming to a surface of the first capacitor electrode; and a second capacitor electrode disposed on the capacitor dielectric layer opposite the first capacitor electrode. "--

in claim 1.

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II/ Group II: Claims 13-22,38-39,41

Claims 13-22,38-39,41 are allowed because None of the references of record teaches or suggests the claimed INTEGRATED CIRCUIT DEVICES WITH METAL-INSULATOR-METAL CAPACITORS DEVICE having the limitations:

"a dielectric layer on the substrate-, a conductive contact plug extending through an opening in the dielectric layer to contact the substrate and including a widened pad portion extending onto the dielectric layer adjacent the opening; stacked ohmic and barrier patterns disposed on the pad portion of the plug and having sidewalls substantially coplanar with a sidewall of the pad portion; a first capacitor electrode disposed on the barrier pattern; a capacitor dielectric layer on the first capacitor electrode; and a second capacitor electrode on the capacitor dielectric layer opposite the first capacitor electrode. "--

in claim 13.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance".

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## Conclusion

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thinh T Nguyen whose telephone number is 571-272-1790. The examiner can normally be reached on Monday-Friday 9:00am-6:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached at 571-272-1787. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9306 for regular communications and (703) 872-9319 for After Final communications.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval [ PAIR ] system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Thinh T Nguyen

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Ngen Van Ngo Primary Examiner

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